



Part Number: DMG6968U-p, DMG3415U-p, DMG2301U-p p = package indicator See Data Sheet Weight (mg): 8.88

Element	Material Group	Materials	CAS (if applicable)	Average mass homogeneous Materal(%)		Mass (mg)	ppm Homogeneous Material	ppm overall
Chip	Silicon w/Metal	Doped Silicon*	7440-21-3	100.00%	3.45	0.31	1000000	34489
		Cu	7440-50-8	97.40%	29.62		974000	288534
Leadframe	CDA-194	Fe	7439-89-6	2.40%		2.63	24000	7110
Leadirame	CDA-194	Р	7723-14-0	0.08%	29.62		800	237
		Zn	7440-66-6	0.12%			1200	355
Leadframe Plating	Silver	Silver	7440-22-4	100.00%	1.16	0.10	1000000	11643
Bond Wire	Copper Wire	Cu	7440-50-8	100.00%	1.06	0.09	1000000	10618
	KTMC-1050G	SiO2	60676-86-0	69.00%	60.32	2 5.36	690000	416241
		Epoxy Resin	29690-82-2	14.00%			140000	84455
Encapsulation		Phenol Resin	9003-35-4	7.00%			70000	42227
Encapsulation		Mg(OH)2	1309-42-8	8.00%			80000	48260
		С	1333-86-4	0.20%			2000	1206
		others (wax, catalyst, coupling agent)		1.80%			18000	10858
Die attached epoxy	84-1 LMISR4	Ag	7440-22-4	75.00%	1.50	0.13	750000	11249
		epoxy resin	Trade secret	20.00%			200000	3000
		curing agent & hardener	Trade secret	5.00%			50000	750
Lead Plating Finish	Matte Tin	Tin	7440-31-5	100.00%	2.88	0.26	1000000	28769
				Total	100.00	8.88		1000000

Tolerance

This data is based on information provided by our suppliers. We believe it to be correct but do not routinely validate it by measurement. It is for guidance only and Diodes Inc. does not guarantee its absolute accuracy or completeness. See the applicable Data Sheet for any Date Code limits.

This product or product family does not contain any of the following substances except as CURRENTLY exempted by ELV II and RoHS and reported above:

Asbestos Antimony Compounds

Azo compounds

Cadmium and cadmium compounds

Certain Shortchain Chlorinated Paraffins Chlorinated organic compounds

Halogens

Hexavalent chromium compounds

Lead and lead compounds

Mercury and mercury compounds

REACH SVHCs: Anthracene

4,4'- Diaminodiphenylmethane

Dibutyl phthalate Cyclododecane

Cobalt dichloride Diarsenic pentaoxide Diarsenic trioxide Sodium dichromate, dihydrate Organic tin compounds

Ozone Depleting Substances - Class I (CFCs, HBFCs, etc.) Ozone Depleting Substances - Class II (HCFCs)

Perfluorooctane Sulphonate (PFOS) or related compounds

Polybrominated biphenyls (PBB) and Polybrominated diphenyl ethers (PBDE) including DecaBDE

Polychlorinated Biphenyls (PCBs)

Polychlorinated Naphthalenes (> 3 chlorine atoms)

Tributyl Tin (TBT) and Triphenyl Tin (TPT) Tributyl Tin Oxide (TBTO)

5-tert-butyl-2,4,6-trinitro-m-xylene (musk xylene) Bis (2-ethyl(hexyl)phthalate) (DEHP)

Hexabromocyclododecane (HBCDD)

Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins)

Bis(tributyltin)oxide Lead hydrogen arsenate Triethyl arsenate Benzyl butyl phthalate

^{*} The Silicon Chip is doped at atomic levels with trace amounts of elements that may include Phosphorus, Boron, Arsenic, and other elements. Metalization may include Titanium, Nickel, Aluminum, Silver or Gold These substances are not reported where their concentration is less than the minimum reportable level per the guidelines specified in the Tables of EIA JIG-101,





Part Number: DMG4413LSS-P p = package indicator Weight (mg): 76.90 See Data Sheet

Element	Material Group	Materials	CAS (if applicable)	Average mass homogeneous Materal(%)		Mass (mg)	ppm Homogeneous Material	ppm overall
Chip	Silicon w/Metal	Doped Silicon*	7440-21-3	100.00%	5.18	3.98	1000000	51756
		Cu	7440-50-8	97.40%	50.75		974000	494344
Leadframe	CDA-194	Fe	7439-89-6	2.40%		39.03	24000	12181
Leadirame	CDA-194	Р	7723-14-0	0.08%			800	406
		Zn	7440-66-6	0.12%			1200	609
Leadframe Plating	Silver	Silver	7440-22-4	100.00%	0.93	0.71	1000000	9285
Bond Wire	Copper Wire	Copper	7440-50-8	100.00%	1.28	0.98	1000000	12755
	EME-G700	Epoxy Resin		7.50%	37.57	28.89	75000	28180
		Phenol Resin		5.00%			50000	18787
Encapsulation		Bismuth/Bismuth compound		0.05%			500	188
		SiO2	60676-86-0	86.95%			869500	326704
		С	1333-86-4	0.50%			5000	1879
Die Attach Epoxy		Ag	7440-22-4	75.00%	2.08	1.60	750000	15621
	84-1 LMISR4	epoxy resin	Trade secret	20.00%			200000	4166
		curing agent & hardener	Trade secret	5.00%			50000	1041
Lead Plating Finish	Matte Tin	Tin	7440-31-5	100.00%	2.21	1.70	1000000	22100
	-		_	Total	100.00	76.90		1000000

±10% Tolerance

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This product or product family does not contain any of the following substances except as CURRENTLY exempted by ELV II and RoHS and reported above:

Organic tin compounds

Antimony Compounds Ozone Depleting Substances - Class I (CFCs, HBFCs, etc.) Azo compounds Ozone Depleting Substances - Class II (HCFCs) Cadmium and cadmium compounds Perfluorooctane Sulphonate (PFOS) or related compounds

Certain Shortchain Chlorinated Paraffins Polybrominated biphenyls (PBB) and Polybrominated diphenyl ethers (PBDE) including DecaBDE

Chlorinated organic compounds Polychlorinated Biphenyls (PCBs)

Halogens Polychlorinated Naphthalenes (> 3 chlorine atoms) Hexavalent chromium compounds Radioactive Substances

Tributyl Tin (TBT) and Triphenyl Tin (TPT) Lead and lead compounds

Mercury and mercury compounds Tributyl Tin Oxide (TBTO)

REACH SVHCs:

Anthracene 5-tert-butyl-2,4,6-trinitro-m-xylene (musk xylene) 4,4'- Diaminodiphenylmethane

Bis (2-ethyl(hexyl)phthalate) (DEHP) Hexabromocyclododecane (HBCDD) Dibutyl phthalate

Cyclododecane Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins)

Cobalt dichloride Bis(tributyltin)oxide Diarsenic pentaoxide Lead hydrogen arsenate Diarsenic trioxide Triethyl arsenate Sodium dichromate, dihydrate Benzyl butyl phthalate

^{*} The Silicon Chip is doped at atomic levels with trace amounts of elements that may include Phosphorus, Boron, Arsenic, and other elements. Metalization may include Titanium, Nickel, Aluminum, Silver or Gold These substances are not reported where their concentration is less than the minimum reportable level per the guidelines specified in the Tables of EIA JIG-101,





Part Number: DMG1016V-p p = package indicator Weight (mg): 3.05 See Data Sheet

Element	Material Group	Materials	CAS (if applicable)	Average mass homogeneous Materal(%)		Mass (mg)	ppm Homogeneous Material	ppm overall
Chip	Silicon w/Metal	Doped Silicon*	7440-21-3	100.00%	5.78	0.18	1000000	57818
		Cu	7440-50-8	99.26%	34.59	1.06	992600	343302
Leadframe	EFTEC-64T	Cr(not Cr 6+)	7440-47-3	0.27%			2700	934
Leauname	EFIEC-041	Sn	7440-31-5	0.25%			2500	865
		Zn	7440-66-6	0.22%			2200	761
Leadframe Plating	Silver	Silver	7440-22-4	100.00%	0.52	0.02	1000000	5173
Bond Wire	Gold	Au	7440-57-5	100.00%	1.29	0.04	1000000	12899
		SiO2	60676-86-0	87.30%			873000	486232
	CEL-1702HF-9	Epoxy Resin	29690-82-2	5.00%	55.70	1.70	50000	27848
Encapsulation		Phenol Resin	26834-02-6	5.00%			50000	27848
		Aromatic poly-phosphate		2.50%			25000	13924
		С	1333-86-4	0.20%			2000	1114
Lead Plating Finish	Matte Tin	Tin	7440-31-5	100.00%	2.13	0.07	1000000	21281
_	_			Total	100.00	3.05		1000000

±10% Tolerance

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This product or product family does not contain any of the following substances except as CURRENTLY exempted by ELV II and RoHS and reported above:

Asbestos Organic tin compounds

Antimony Compounds Ozone Depleting Substances - Class I (CFCs, HBFCs, etc.) Azo compounds Ozone Depleting Substances - Class II (HCFCs) Cadmium and cadmium compounds Perfluorooctane Sulphonate (PFOS) or related compounds

Polybrominated biphenyls (PBB) and Polybrominated diphenyl ethers (PBDE) including DecaBDE Certain Shortchain Chlorinated Paraffins Chlorinated organic compounds Polychlorinated Biphenyls (PCBs)

Halogens Polychlorinated Naphthalenes (> 3 chlorine atoms) Hexavalent chromium compounds Radioactive Substances

Tributyl Tin (TBT) and Triphenyl Tin (TPT)

Lead and lead compounds Tributyl Tin Oxide (TBTO) Mercury and mercury compounds

REACH SVHCs: Anthracene 5-tert-butyl-2,4,6-trinitro-m-xylene (musk xylene) 4,4'- Diaminodiphenylmethane Bis (2-ethyl(hexyl)phthalate) (DEHP) Hexabromocyclododecane (HBCDD)

Dibutyl phthalate Cyclododecane Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins)

Cobalt dichloride Bis(tributyltin)oxide Diarsenic pentaoxide Lead hydrogen arsenate Triethyl arsenate Benzyl butyl phthalate Diarsenic trioxide Sodium dichromate, dihydrate

^{*} The Silicon Chip is doped at atomic levels with trace amounts of elements that may include Phosphorus, Boron, Arsenic, and other elements. Metalization may include Titanium, Nickel. Aluminum, Silver or Gold These substances are not reported where their concentration is less than the minimum reportable level per the guidelines specified in the Tables of EIA JIG-101,





Part Number: **DMG6968UDM-p, DMG9926UDM-p** p = package indicator Weight (mg): 16.55 See Data Sheet

Element	Material Group	Materials	CAS (if applicable)	Average mass homogeneous Materal(%)	Percent of whole (%)	Mass (mg)	ppm Homogeneous Material	ppm overall
Chip	Silicon w/Metal	Doped Silicon*	7440-21-3	100.00%	4.16	0.69	1000000	41574
		Cu	7440-50-8	99.26%			992600	411974
Leadframe	EFTEC-64T	Cr(not Cr 6+)	7440-47-3	0.27%	41.50	6.87	2700	1121
Leauname	LI ILC-041	Sn	7440-31-5	0.25%	41.50		2500	1038
		Zn	7440-66-6	0.22%			2200	913
Leadframe Plating	Silver	Silver	7440-22-4	100.00%	0.80	0.13	1000000	8041
Bond Wire	Copper	Cu	7440-50-8	100.00%	1.57	0.26	1000000	15682
	CEL-1702HF9	SiO2	60676-86-0	87.30%	45.52	7.54	873000	397395
		Epoxy Resin	29690-82-2	5.00%			50000	22760
Encapsulation		Phenol Resin	26834-02-6	5.00%			50000	22760
		Aromatic poly-phosphate		2.50%			25000	11380
		С	1333-86-4	0.20%			2000	910
	84-1 LMISR4	Ag	7440-22-4	75.00%	1.74		750000	13071
Die Attach Epoxy		epoxy resin	Trade secret	20.00%		0.29	200000	3486
		curing agent & hardener	Trade secret	5.00%			50000	871
Lead Plating Finish	Matte Tin	Tin	7440-31-5	100.00%	4.70	0.78	1000000	47023
			·	Total	100.00	16.55		1000000

Tolerance ±10%

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This product or product family does not contain any of the following substances except as CURRENTLY exempted by ELV II and RoHS and reported above:

Asbestos Organic tin compounds

Antimony Compounds
Ozone Depleting Substances - Class I (CFCs, HBFCs, etc.)
Azo compounds
Ozone Depleting Substances - Class II (HCFCs)
Cadmium and cadmium compounds
Perfluorooctane Sulphonate (PFOS) or related compounds

Certain Shortchain Chlorinated Paraffins
Polybrominated biphenyls (PBB) and Polybrominated diphenyl ethers (PBDE) including DecaBDE

Chlorinated organic compounds Polychlorinated Biphenyls (PCBs)

Halogens Polychlorinated Naphthalenes (> 3 chlorine atoms)
Hexavalent chromium compounds Radioactive Substances

Lead and lead compounds Tributyl Tin (TBT) and Triphenyl Tin (TPT)

Mercury and mercury compounds Tributyl Tin Oxide (TBTO)

REACH SVHCs:

Anthracene 5-tert-butyl-2,4,6-trinitro-m-xylene (musk xylene)
4,4'- Diaminodiphenylmethane Bis (2-ethyl(hexyl)phthalate) (DEHP)
Dibutyl phthalate Hexabromocyclododecane (HBCDD)

Cyclododecane Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins)

 Cobalt dichloride
 Bis(tributyltin)oxide

 Diarsenic pentaoxide
 Lead hydrogen arsenate

 Diarsenic trioxide
 Triethyl arsenate

 Sodium dichromate, dihydrate
 Benzyl butyl phthalate

^{*} The Silicon Chip is doped at atomic levels with trace amounts of elements that may include Phosphorus, Boron, Arsenic, and other elements. Metalization may include Titanium, Nickel, Aluminum, Silver or Gold These substances are not reported where their concentration is less than the minimum reportable level per the guidelines specified in the Tables of EIA JIG-101,





Part Number: DMG6968UTS-p, DMG8822UTS-p p = Packaging Code Weight (mg): 40.81 See Data Sheet

Element	Material Group	Materials	CAS (if applicable)	Average mass homogeneous Materal(%)		Mass (mg)	ppm Homogeneous Material	ppm overall
Chip	Silicon w/Metal	Doped Silicon*	7440-21-3	100.00%	1.69	0.69	1000000	16863
		Cu	7440-50-8	95.90%			959000	398701
Leadframe	C7025	Si	7440-21-3	0.73%	41.57	16.97	7250	3014
Leauname	C/025	Ni	7440-02-0	3.20%	41.37		32000	13304
		Mg	7439-95-4	0.18%			1750	728
Leadframe Plating	Silver	Silver	7440-22-4	100.00%	1.70	0.69	1000000	16981
Bond Wire	Copper Wire	Copper	7440-50-8	100.00%	0.99	0.41	1000000	9941
		Epoxy Resin		7.50%	53.24	21.73	75000	39927
		Phenol Resin		5.00%			50000	26618
Encapsulation	EME-G700	Bismuth/Bismuth compound		0.05%			500	266
		SiO2	60676-86-0	86.95%			869500	462889
		С	1333-86-4	0.50%			5000	2662
		Ag	7440-22-4	66.50%	0.59		665000	3894
		Epoxy Resin		20.00%		0.24	200000	1171
Die Attach Epoxy	8352L	Aliphatic anhydride		7.50%			75000	439
		2-Butoxyethyl acetate	112-07-2	3.00%			30000	176
		Polymeric material		3.00%			30000	176
Lead Plating Finish	Matte Tin	Tin	7440-31-5	100.00%	0.22	0.09	1000000	2249
				Total	100.00	40.81		1000000

Tolerance ±10%

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This product or product family does not contain any of the following substances except as CURRENTLY exempted by ELV II and RoHS and reported above:

sbestos Organic tin compound

Antimony Compounds
Ozone Depleting Substances - Class I (CFCs, HBFCs, etc.)
Azo compounds
Ozone Depleting Substances - Class II (HCFCs)
Cadmium and cadmium compounds
Perfluorooctane Sulphonate (PFOS) or related compounds

Certain Shortchain Chlorinated Paraffins
Polybrominated biphenyls (PBB) and Polybrominated diphenyl ethers (PBDE) including DecaBDE

Chlorinated organic compounds Polychlorinated Biphenyls (PCBs)

Halogens Polychlorinated Naphthalenes (> 3 chlorine atoms)
Hexavalent chromium compounds Radioactive Substances

Lead and lead compounds

Tributyl Tin (TBT) and Triphenyl Tin (TPT)

Mercury and mercury compounds

Tributyl Tin Oxide (TBTO)

REACH SVHCs:

Anthracene 5-tert-butyl-2,4,6-trinitro-m-xylene (musk xylene)
4,4- Diaminodiphenylmethane Bis (2-ethyl(hexyl)phthalate) (DEHP)
Dibutyl phthalate Hexabromocycloddecane (HBCDD)

Cyclododecane Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins)

 Cobalt dichloride
 Bis(tributyltin)oxide

 Diarsenic pentaoxide
 Lead hydrogen arsenate

 Diarsenic trioxide
 Triethyl arsenate

 Sodium dichromate, dihydrate
 Benzyl butyl phthalate

^{*} The Silicon Chip is doped at atomic levels with trace amounts of elements that may include Phosphorus, Boron, Arsenic, and other elements. Metalization may include Titanium, Nickel, Aluminum, Silver or Gold These substances are not reported where their concentration is less than the minimum reportable level per the guidelines specified in the Tables of EIA JIG-101,